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PATENT
2674-000003/US

IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant: Micronic Laser Systems AB Conf.: 9874
Appl. No.: 09/623,195 Group: 2873
Filed: August 29, 2000 William C. Choi
Patent No.: 6,747,783 Issued: 6/8/2004
For: PATTERN GENERATOR

ASSERTION OF LARGE ENTITY STATUS

Assistant Commissioner for Patents
Washington, DC 20231

June 25, 2007

Sir:

The above-identified application qualifies for large entity status. This written assertion of Large entity status should satisfy the requirements of 37 C.F.R. § 1.27.

If necessary, the Commissioner is hereby authorized in this, concurrent, and future replies, to charge payment or credit any overpayment to Deposit Account No. 08-0750 for any additional fees required under 37 C.F.R. § 1.16 or under 37 C.F.R. § 1.17; particularly, extension of time fees.

Respectfully submitted,

HARNESS, DICKEY & PIERCE, P.L.C.

By

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